

Photocatalytic Decomposition of N₂O on Highly Dispersed Ag⁺ Ions on TiO₂ Prepared by Photodeposition

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Nitrous oxide (N₂O) was photocatalytically decomposed on Ag-photodeposited TiO₂ in the presence of methanol vapor. The N₂O decomposition activity of Ag-photodeposited TiO₂ was much higher than that of Ag-loaded TiO₂ prepared by deposition–precipitation or impregnation methods. The difference in the N₂O decomposition activity between the preparation methods was discussed in terms of the surface conditions observed by transmittance electron microscopy and X-ray photoelectron spectroscopy. The N₂O decomposition activity depended on the amount of photodeposited Ag, and the TiO₂ loaded with only 0.16 wt% Ag has revealed the highest level of activity. Highly dispersed Ag⁺ ions prepared by photodeposition were effective for the photocatalytic decomposition of N₂O. In the deposition–precipitation or impregnation methods, Ag⁺ ions aggregated to form Ag particles and the N₂O decomposition activity of these catalysts showed a low level of efficiency. Nitrogen of N₂O was reduced into N₂ gas, whereas oxygen was released as CO or CO₂ by the reaction with methanol or its derivatives. © 2000

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Key Words: N₂O decomposition; photocatalyst; TiO₂; Ag; photodeposition.

INTRODUCTION

The techniques for suppression of nitrous oxide (N₂O) emission and removal of N₂O from the atmosphere are strongly desired because of the contributions of N₂O to the global warming and ozone layer depletion. The global warming potential of N₂O is 320 times higher than that of CO₂ (1). As N₂O is kinetically stable but thermodynamically unstable, its lifetime in the atmosphere is long, about 120–150 years (1, 2). Moreover, the N₂O concentration in the atmosphere (ca. 0.31 ppm in 1992) is increasing by 0.25% every year (1, 3).

Photocatalytic decomposition of N₂O is one of the candidate methods for its removal. N₂O can be reduced by the electrons generated by UV irradiation on semiconductor photocatalysts, evolving N₂ (4–7). Since photocatalysts

are suitable for treatment of low-concentration gases and are used at room temperature with sunlight as the energy source (8), photocatalytic decomposition has many advantages: the concentration process is not necessary, the reaction condition is mild, and utilization of sunlight leads to energy savings. Several authors have reported photocatalytic decomposition of N₂O using praseodymium catalysts, lanthanoid cation-exchanged mordenites (9), Cu ion-containing ZSM-5 (10), ZnO, Fe₂O₃ (4), and titanium oxide anchored onto porous vycor glass (5). However, either the quantum yields of the photocatalytic decomposition reaction were low or the photocatalysts were activated with short-wavelength photons (<300 nm), i.e., not included in the sunlight spectrum.

Titanium dioxide (TiO₂) is well known as a photocatalyst for elimination of environmental pollutants and is a harmless white powder (8, 11–15). The TiO₂ photocatalyst absorbs photons with wavelengths below 400 nm and promotes redox reactions on its surface. The photocatalytic activity of TiO₂ is applied for NO_x removal (12), reduction of CO₂ (13), water splitting (14), decomposition of VOC (8, 15), etc., on a laboratory scale. However, pure TiO₂ does not decompose N₂O even if a reductant is added to the system. In our preliminary experiment, deposition of Pt, Cu, or Ag on TiO₂ as co-catalyst enabled the photocatalytic reaction to proceed in the presence of methanol vapor. Also, Kudo and co-workers reported that TiO₂ with Ag, Cu, Ru, and Pt as co-catalysts photocatalytically decomposes N₂O at room temperature in the presence of methanol and water vapor (6, 7).

In particular, Ag-loaded TiO₂ showed a high level of activity for the photocatalytic decomposition of N₂O, and the addition of Ag to TiO₂ catalyst has been reported to enhance the reduction of NO and thiols (16, 17). However, the states of Ag species (such as oxidation state or dispersion) on TiO₂ surfaces are not well understood. Since the photocatalytic decomposition of N₂O is a heterogeneous process, the surface condition of the photocatalyst should affect the N₂O decomposition activity. Furthermore, the improvement of the catalyst surface would be an important factor in decomposing N₂O efficiently.

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In this paper, Ag-loaded TiO₂ photocatalysts (Ag-TiO₂) for N₂O decomposition were prepared by photodeposition, deposition-precipitation, and impregnation methods. The N₂O decomposition activity of the photocatalysts determined by X-ray diffractometry (XRD), X-ray photoelectron spectroscopy (XPS), and transmittance electron microscopy (TEM). The mechanism of the photocatalytic process is also discussed.

METHODS

Preparation of Photocatalysts

The Ag-TiO₂ photocatalysts were synthesized by photodeposition, deposition-precipitation, and impregnation methods (16–21). AgNO₃ (analytical grade) and anatase-type TiO₂ (Degussa, P-25) were used. The amount of Ag loaded varied between 0.01 and 2.0 wt% versus TiO₂.

Photodeposition method. A 3.0-g portion of TiO₂ was dispersed into 75 cm³ of AgNO₃ solution (3.7×10^{-5} to 7.4×10^{-3} mol dm⁻³). The pH of the suspension was adjusted to 6.3 by addition of KOH solution (0.01–0.1 mol dm⁻³) while the suspension was stirred vigorously by a magnetic stirrer. The suspension was aged for 15 min at room temperature. Then, 2 cm³ of methanol was added to the suspension, before being poured into the quartz cell for photodeposition. UV light from a high-pressure Hg lamp (Ushio, USH-500D, 500 W) was irradiated to the suspension through a longpass filter (cut-off wavelength 295 nm) for 30 min while N₂ gas was passed through the suspension (photodeposition process). The product was collected by the aid of centrifugation, washed with distilled water four times, and then dried in air at 383 K for 12 h.

Impregnation method. TiO₂ was dispersed into AgNO₃ solution containing the required amount of Ag and dried in air at 383 K. The precursor was heat-treated in air at 773 K for 3 h to form Ag-TiO₂.

Deposition-precipitation method. TiO₂ was dispersed in AgNO₃ solution containing the required amount of Ag. The pH of the suspension was adjusted to 6.8 by adding KOH solution (0.01–0.1 mol dm⁻³) to precipitate Ag⁺ ions on TiO₂. The precipitate was collected by the aid of centrifugation, washed with distilled water four times, and then dried in air at 383 K for 12 h. The precipitate was heat-treated in air at 473 or 573 K for 6 h to obtain Ag-TiO₂ catalysts. The activity of the former (473 K heat treatment) was 20% lower than that of the latter (573 K heat treatment). Thus, only the sample heat-treated at 573 K was used in the present paper.

The solid phases were identified by XRD with CuK α radiation (Rigaku, Model RU-300), XPS with AlK α radiation (Fisons Instruments, Escalab220i-XL), and TEM (Philips,

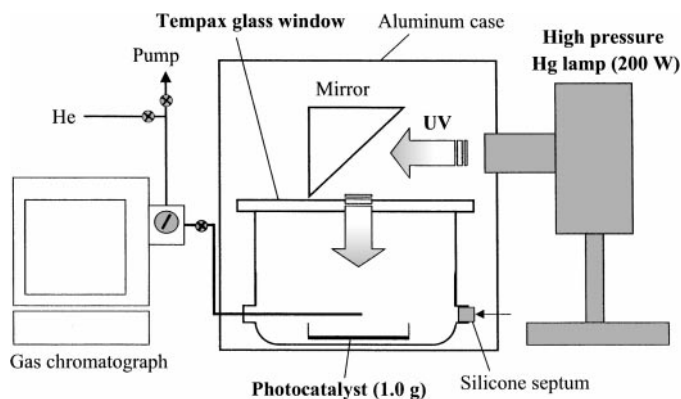


FIG. 1. Experimental set-up for photocatalytic decomposition of N₂O (sample 1.0 g; vessel volume 1830 cm³; irradiated area 50 cm²; UV-A irradiance at the sample 1.8 mW cm⁻²).

CM30). The amount of Ag deposited was determined by X-ray fluorescence analysis (XRF; Philips, PW2404) and inductively coupled plasma spectrometry (ICP; Shimadzu, ICPS7000).

Photocatalytic Decomposition of N₂O

The experimental set-up is schematically shown in Fig. 1. A 1.0-g portion of the Ag-TiO₂ photocatalyst was dispersed on a laboratory glass dish (8 cm in diameter) that was placed in the reaction vessel (1.83 dm³) with a cover window of Tempax glass (8 mm in thickness, cut-off wavelength of 300 nm). After the reaction vessel was filled with He to the atmospheric pressure, N₂O was injected into the vessel through a silicone septum with a syringe. In the study of the effect of methanol or water vapor, liquid methanol or water was also injected through the septum to be vaporized. The temperature at the center of the sample was monitored with a thermocouple. No significant increase in the temperature was observed during the photoreactions. During the photocatalytic decomposition of N₂O, the photocatalyst was irradiated with UV light from a high-pressure mercury lamp (Ushio, USH-102D, 200 W) through the Tempax glass window. The UV irradiance at the sample surface was approximately 1.8 mW cm⁻². Gases in the reaction vessel were analyzed using a gas chromatograph (Shimadzu, GC8A) and gas chromatograph-mass spectrometry (GC-MS) (Hewlett Packard, GC-MS5972A).

RESULTS AND DISCUSSION

Characterization of the Photocatalysts

The photocatalysts prepared by photodeposition, deposition-precipitation, and impregnation methods are abbreviated as PD_x, DP_x, and IM_x, where *x* denotes the weight percentage of loaded Ag versus TiO₂, which was determined by XRF. The typical photocatalysts

TABLE 1
Photocatalysts Prepared and Studied

Sample	Method	Ag (wt% against TiO ₂)		Temperature ^c (K)	Crystallite size ^d (nm)
		In suspension ^a	On TiO ₂ ^b		
TiO ₂		0	0	383	25
PD1.60	Photodeposition	2.00	1.6	383	26
PD0.16	Photodeposition	0.20	0.16	383	24
DP0.67	Deposition-precipitation	1.00	0.67	573	25
DP0.11	Deposition-precipitation	0.10	0.11	573	25
IM0.90	Impregnation	1.00	0.90	773	24
IM0.10	Impregnation	0.10	0.10	773	25

^a Amount of Ag contained in the preparation suspension.

^b Amount of Ag loaded on TiO₂ determined by XRF.

^c Highest temperature of heat treatment.

^d Crystallite size of TiO₂ (anatase) calculated from XRD pattern.

prepared are listed in Table 1 along with their preparation conditions. For the impregnation method, the amounts of Ag loaded were identical with the amount of Ag in the preparation suspension. For the deposition-precipitation and photodeposition methods, the amount of Ag loaded was equal to or lower than that contained in the preparation suspension. This indicates that the Ag⁺ ion in the preparation suspension was not completely deposited on TiO₂. The relation between the amounts of Ag in the preparation suspension and on the TiO₂ photocatalyst prepared by the photodeposition method is shown in Fig. 2. The difference between the amounts of Ag in suspension and on TiO₂ increased with increasing amounts of Ag in suspension. In the present study, UV-irradiation time for photodeposition was set to be constant (30 min), regardless of the Ag content. It is considered that the UV-irradiation time was short for the photodeposition of a larger amount

of Ag and that all of Ag⁺ ions in the suspension were not photodeposited.

In the XRD patterns of all photocatalysts, only the peaks of TiO₂, anatase and rutile, appeared but no peaks of Ag or Ag-related compounds were detected. This indicates that the Ag was loaded in the state of ions or small nondetectable particles. The *d*-spacing of the anatase or rutile in the photocatalysts was identical to that of the raw material. The crystallite sizes of the anatase in the photocatalysts were determined from the half-width of the 200 plane of anatase crystal using the Scherrer formula ($t = 0.9\lambda / B \cos \theta$) and are listed in Table 1. The crystallite sizes of all the photocatalysts were similar (24–26 nm) and were not dependent on the preparation method. This indicates that sintering of TiO₂ crystallite does not proceed significantly at temperatures below 773 K. Therefore, the specific surface areas of the photocatalysts are consistent with that of the initial material (P-25, $\sim 50 \text{ m}^2 \text{ g}^{-1}$).

The characteristics of Ag deposited on the photocatalysts were analyzed by XPS. Figure 3 shows the Ag 3*d* spectra for the photocatalysts. The peaks at around 367 eV (Ag 3*d*_{5/2}) in the XPS spectra are slightly broadened and are considered to be the sum of multiple peaks. Figure 4a shows the results of curve fitting for PD1.6 by a complex of Lorentzian and Gaussian curves. The spectra for other samples were also divided into two peaks, *a* (368.2 eV) and *b* (367.6 eV). The information for the curves is listed in Table 2. The resolved peaks *a* and *b* can be attributed to the peaks of metal Ag and Ag⁺ (Ag₂O), respectively (22, 23). In all the spectra, the peak for Ag⁺ ions is larger than the peak for metal Ag. During the preparation process by photodeposition, Ag⁺ ions in the suspension were reduced on the TiO₂ surface and were deposited as metal Ag (21). However, a part of photodeposited Ag could have been oxidized to Ag⁺ in air after preparation. In the deposition-precipitation and impregnation methods, Ag species deposited on the photocatalysts were partially reduced to metal Ag during the heat

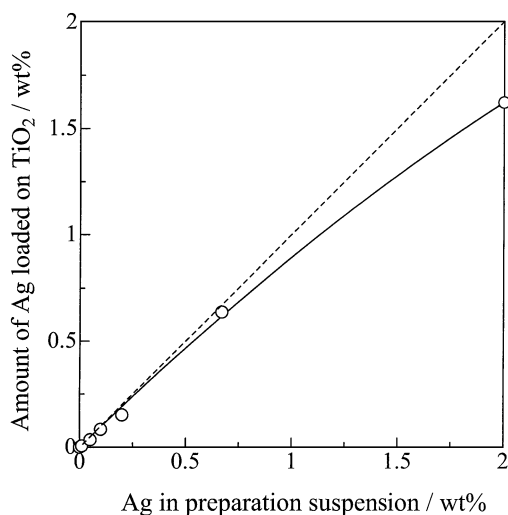


FIG. 2. Relation between the amount of Ag contained in the preparation suspension and the amount loaded on TiO₂.

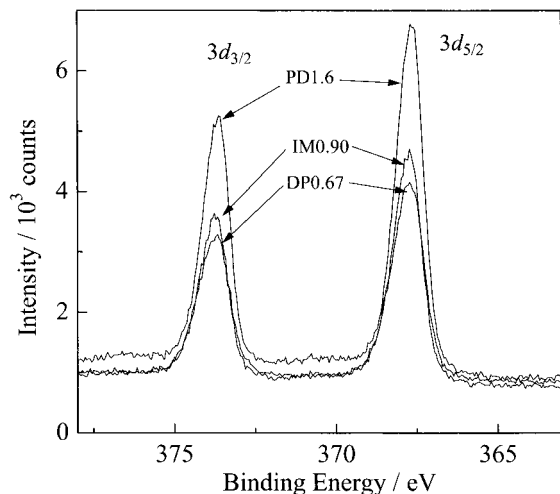


FIG. 3. XPS spectra of the Ag-TiO₂ photocatalysts prepared by photodeposition, deposition-precipitation and impregnation methods.

treatment (573 K for deposition-precipitation and 773 K for impregnation methods), and both metal Ag and Ag⁺ ions were detected.

The integrated intensity of the Ag 3d_{5/2} peak for PD1.6 is 9 times higher than that for PD0.16 (Table 2). This roughly coincides with the ratio of loaded Ag amounts (10 times) determined by XRF. On the other hand, the intensity for

TABLE 2

Results of XPS for Ag-TiO₂ Photocatalysts

Sample	Binding energy (eV)		Relative intensity (arbitrary unit)			Total
	Peak a	Peak b	Peak a	Peak b	b/a+b	
PD1.60	368.2	367.6	1.63	7.45	0.72	9.08
PD0.16	368.2	367.6	0.23	0.77	0.77	1.00
DP0.67	368.2	367.6	2.16	4.18	0.66	6.34
DP0.11	—	367.5	—	0.10	—	0.10
IM0.90	368.2	367.7	2.28	5.24	0.70	7.52
IM0.10	368.2	367.7	0.04	0.33	0.89	0.37

DP0.11 or IM0.10 is much smaller than that for DP0.67 or IM0.90, respectively, even if the amounts of Ag deposited are considered. This suggests that the amount of Ag existing on the surface was different from the amount of Ag loaded. This may be due to the diffusion of Ag from the TiO₂ surface to the interior during the heat treatment.

Figures 5a–5f show the TEM photographs of the photocatalysts. The crystallite sizes of all photocatalysts observed by TEM are approximately identical with the values determined by XRD. Figure 5a is the TEM photograph of PD0.16. No significant changes in surface conditions are observed, and the photograph is almost similar to that of the initial material (TiO₂, P-25). In the photograph for PD1.6 (Fig. 5b), the small particles of Ag with a diameter of 1–2 nm are noticeable. They might be formed on the surface by aggregation of Ag in the photodeposition process when a large amount of Ag is photodeposited. The aggregation of Ag could be probably explained by both the high Ag⁺ concentration and the large absolute amount of Ag⁺ in the preparation suspension. The aggregation of Ag is more obvious on the photocatalysts prepared by deposition-precipitation and impregnation methods. In both preparation methods, only 0.1 wt% of loaded Ag forms the Ag particles (Fig. 5c for DP0.11 and Fig. 5e for IM0.10).

Based on the results of XPS, a larger amount of Ag exists on the surface of PD0.16 than on the surface of DP0.11 or IM0.10. However, the aggregation of Ag is not confirmed on PD0.16. Therefore, Ag species on PD0.16 are highly dispersed, compared with DP0.11 or IM0.10. The number of Ag particles observed on PD1.6 is not so different from that on DP0.11 or DP0.67, while the Ag peak intensity in XPS spectrum for the PD1.6 is larger than that of DP0.11 or DP0.67. This suggests that a large proportion of the Ag species was well dispersed on PD1.6 and a small proportion of the Ag species aggregated on the surface.

A rough surface is observed for IM0.10 and IM0.90 (Figs. 5e and 5f). This may be due to the heat treatment at higher temperature (773 K in air), which would promote the reaction of Ag species with the TiO₂ surface. Although the amounts of Ag loaded on IM0.10 and IM0.90 are different, the degrees of roughness are not so different. This

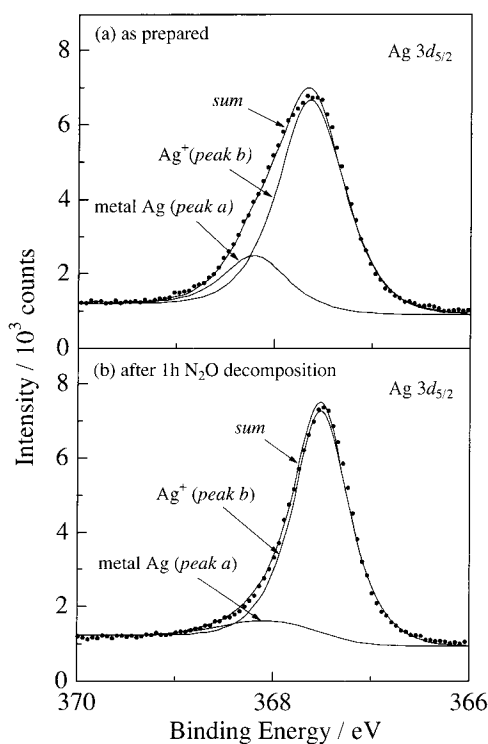


FIG. 4. XPS spectra of Ag-photodeposited TiO₂ (PD1.6) as prepared (a) and after the photocatalytic decomposition of N₂O for 1 h in the presence of methanol and water vapor (b).

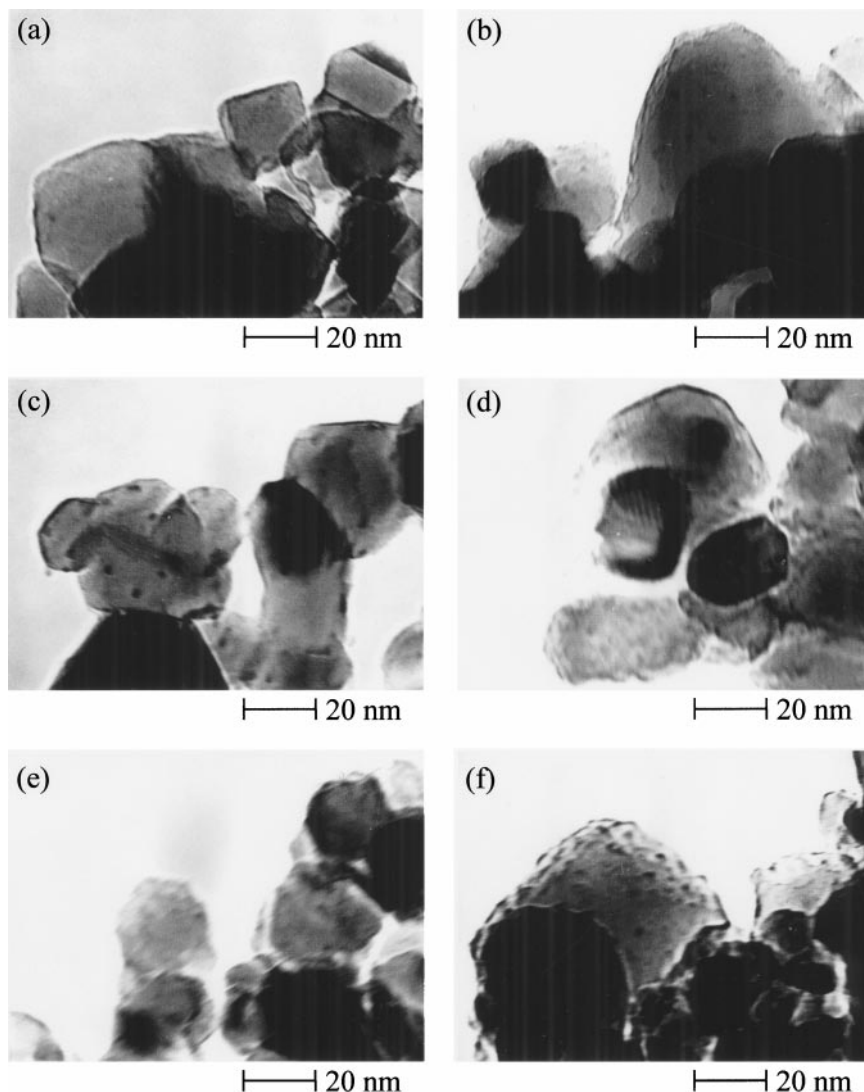


FIG. 5. TEM photographs of Ag-TiO₂ prepared by (a,b) photodeposition, (c,d) deposition-precipitation, and (e,f) impregnation methods. (a) PD0.16, (b) PD1.60, (c) DP0.11, (d) DP0.65, (e) IM0.10, and (f) IM0.90.

suggests that the bumps on the surface are not Ag particles themselves. The bumps may be formed in the course of Ag⁺ migration into the TiO₂ surface layer during the heat treatment. In the photodeposition method, a heat treatment at high temperature was not necessary and the surface of the photocatalysts retained its original shape.

IM0.11 and IM0.90 were dispersed into 1.0 mol dm⁻³ HNO₃ solution, and the amount of Ag dissolved was determined by ICP spectrometry. Only 0.024 and 0.443 wt% of Ag was detected for IM0.11 and IM0.90, respectively. Since these values are much smaller than the amounts of Ag determined by XRF (0.11 and 0.90 wt%), the other part of Ag may combine strongly with TiO₂ and not dissolve in HNO₃ solution. It is considered that Ag⁺ ions migrated into the TiO₂ and that Ag-TiO₂ compounds were formed during the heat treatment at 773 K. On the other hand, the major

part (>90%) of Ag on the photocatalysts prepared by the photodeposition method was dissolved in HNO₃ solution. This suggests that Ag existed on the outermost layer of the photocatalyst and did not bind strongly with TiO₂.

N₂O Decomposition Activities of Ag-TiO₂ Photocatalysts

Figure 6 shows a typical profile for the photocatalytic decomposition of N₂O by Ag-photodeposited TiO₂ (Ag 0.64 wt%) in the presence of methanol (0.63 kPa) and water vapor (1.4 kPa). When the photocatalyst was not irradiated by UV light, N₂O was not decomposed. After the beginning of UV irradiation at time 0, the partial pressure of N₂O decreased from 0.14 to 0.04 kPa within 2 h. Then, additional N₂O was injected into a reaction vessel and the N₂O decomposition was continued while methanol was added

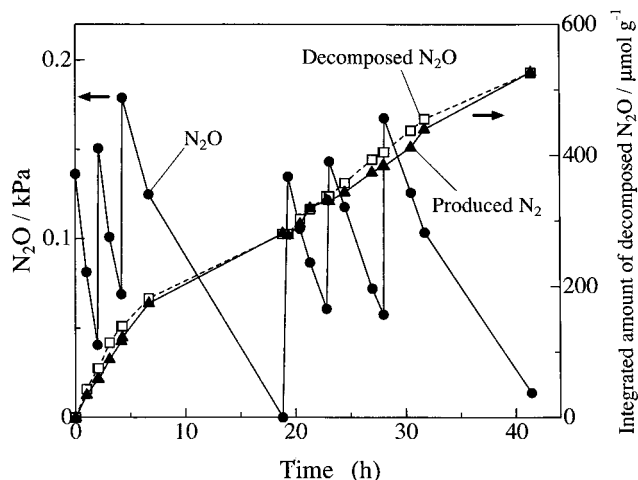
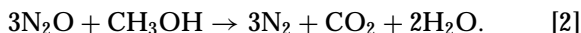
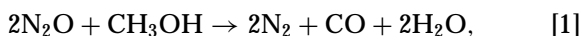


FIG. 6. N_2O decomposition with Ag-photodeposited TiO_2 (Ag 0.64 wt%) under UV irradiation (initial pressure of N_2O 0.14 kPa; MeOH 0.63 kPa; H_2O 1.4 kPa).

occasionally. The Ag-photodeposited TiO_2 lowered the partial pressure of N_2O below 1 Pa (at 18 h). The integrated amount of N_2O decomposed and the amount of N_2 evolved (shown in Fig. 6) were almost equal. This indicates that N_2O was decomposed into N_2 . Oxygen was not produced while a very small amount of H_2 gas was detected. The gas phase contained $100 \mu\text{mol}$ of CO_2 and $32 \mu\text{mol}$ of CO after a 42-h reaction. These results suggest that the oxygen atom of N_2O was released as CO , CO_2 , and H_2O by the reaction with methanol vapor.

The formations of CO_2 and CO are represented by the following stoichiometric equations:



Based on the amounts of CO and CO_2 produced, the amount of N_2O decomposed can be estimated to be $364 \mu\text{mol}$, which is smaller than the amount of N_2O actually decomposed ($520 \mu\text{mol}$). This suggests that a part of the oxygen atom of decomposed N_2O was released as other compounds. The reaction gas mixture was further analyzed by GC-MS. In the gas phase, acetaldehyde, methyl formate, dimethoxymethane, methyl acetate, acetic acid, ethyl acetate, and small amounts of other organic compounds were detected along with unchanged methanol. These organic compounds were produced by the partial oxidation of methanol with oxygen atoms of N_2O . When the addition of methanol was stopped, the concentrations of these organic compounds began to decrease and the CO_2 concentration increased. These results suggest that the partial oxidation of methanol was faster than the complete oxidation of the detected intermediate organic compounds. The depression of the production of intermediate compounds could be realized by controlling the concentration of methanol vapor. Neither NO nor NO_2 was detected in the reaction gas mixture.

The photocatalysts prepared by the photodeposition method decomposed N_2O more rapidly than those prepared by the deposition-precipitation and impregnation methods. Figure 7a shows the photocatalytic decomposition of N_2O by Ag- TiO_2 with low Ag content in the presence of methanol (0.63 kPa) and water vapor (1.4 kPa). The N_2O decomposition rate with PD0.16 was about 12 times higher than that with DP0.11 or IM0.10. Based on the XPS analysis, the amount of Ag present on the surface of the photocatalyst prepared by the photodeposition method is 10 times larger than in the case of photocatalysts prepared by the deposition-precipitation method. The difference in the amount of Ag effective for N_2O decomposition may be one of the factors responsible for the higher activity of PD0.16. However, the difference between the

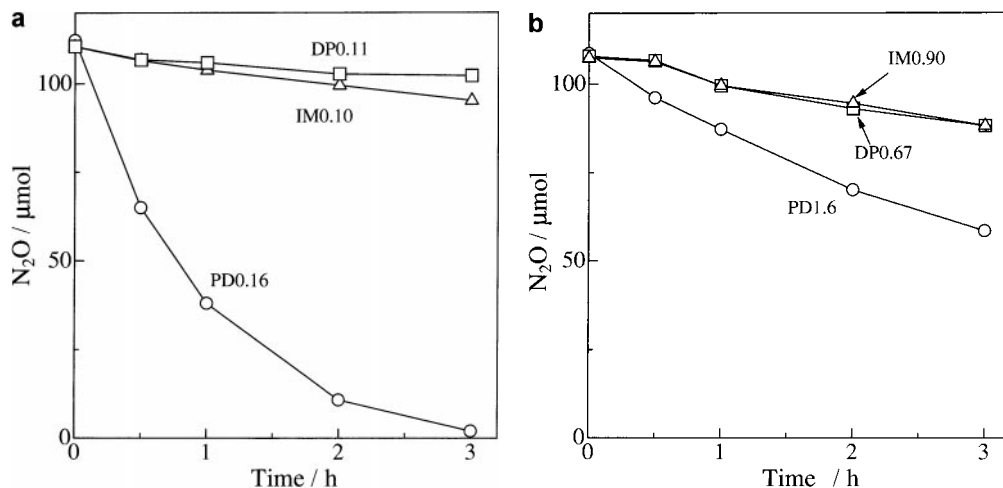


FIG. 7. Decomposition of N_2O by Ag- TiO_2 photocatalysts; (a) low Ag content and (b) high Ag content (initial pressure of N_2O 0.14 kPa; MeOH 0.63 kPa; H_2O 1.4 kPa). (○) Photodeposition, (□) deposition-precipitation, and (△) impregnation methods.

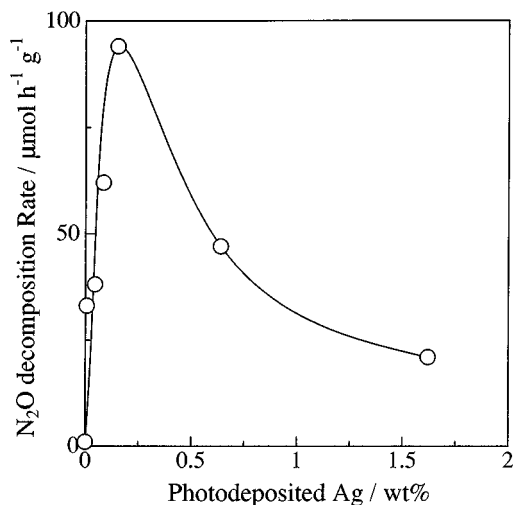


FIG. 8. Effect of the amount of photodeposited Ag on N₂O decomposition rate (initial pressure of N₂O 0.14 kPa; MeOH 0.63 kPa; H₂O 1.4 kPa).

decomposition rates of PD0.16 and IM0.10 is much larger than the difference between the amounts of Ag on PD0.16 and IM0.10 determined by XPS. Therefore, the N₂O decomposition rates may be also due to the states of Ag species on the TiO₂ surface. The dispersion of Ag on PD0.16 seems to be higher than that on DP0.11 or IM0.10, since Ag did not aggregate on PD0.16 while Ag aggregated on DP0.11 and IM0.10 as shown in TEM photographs. The high dispersion of Ag on PD0.16 may enhance the adsorption of N₂O and lead to a higher activity. For the photocatalysts with larger Ag content (Fig. 7b), the difference between the photocatalytic activities of PD1.6 and DP0.67 (or IM0.90) was lower than the difference between those of PD0.16 and DP0.11 (or IM0.10) (Fig. 7b). As the Ag aggregation occurred on PD1.6 similarly to DP0.67 or IM1.0, the dispersion of Ag on PD1.6 may be lower than that on PD0.16, decreasing the photocatalytic activity of PD1.6.

In the photodeposition method, Ag was deposited selectively on the reduction sites of the TiO₂ surface (19). On the other hand, Ag was deposited randomly in the case of the deposition-precipitation or impregnation methods. It can be assumed that the selective deposition on reduction sites is one of the reasons for the higher activity of Ag-photodeposited TiO₂. Since N₂O has been adsorbed and reduced on Ag during the photocatalytic reaction, Ag on the reduction site, where electrons are sufficiently provided, would be a highly active site for N₂O reduction.

The effect of the amount of photodeposited Ag on the N₂O decomposition rate is shown in Fig. 8. The decomposition rate was calculated from the amount of N₂O decomposed during the initial 30 min of UV irradiation. The TiO₂ without Ag deposition did not decompose N₂O at all; however, the TiO₂ with photodeposited Ag decomposed N₂O even when only 0.007 wt% of Ag had been photodeposited. In the case where the amount of photodeposited Ag was

lower than 0.16 wt%, the N₂O decomposition rate increased with the amount of Ag. This suggests that the photodeposited Ag is the active site for the photocatalytic decomposition of N₂O. The maximum decomposition rate (94 μmol h⁻¹ g⁻¹) was obtained with 0.16 wt% Ag-deposited TiO₂ (PD0.16), where the apparent quantum yield was 9.4%. When the amount of Ag was larger than 0.16 wt%, the N₂O decomposition rate decreased with an increasing amount of Ag. This decreasing activity may be due to a diminution of the dispersion of Ag on the TiO₂ surface. As described above, the aggregation of Ag was observed on PD1.6 by TEM, while it was not observed on PD0.16. The aggregation seems to occur when the amount of Ag is over 0.16 wt%, and this may decrease the number of N₂O adsorption sites and thus decrease the photocatalytic decomposition activity, as shown in Fig. 8.

Mechanism of N₂O Decomposition on Ag-TiO₂ Photocatalysts

The oxidation state of Ag on Ag-photodeposited TiO₂ after N₂O decomposition for 1 h in the presence of methanol and water vapor was analyzed by XPS. The spectrum for PD1.6 (Fig. 4b) is similar to that for PD0.16 except for the absolute intensity range. The peak of metal Ag (peak *a*, 368.2 eV) was small, and the large part of Ag existed as Ag⁺ ions of Ag₂O (peak *b*, 367.6 eV). It is considered that the metal Ag in PD1.6 as prepared was oxidized into Ag⁺ ions in the initial stage of the photocatalytic N₂O decomposition. The N₂O decomposition activity did not decrease despite the decrease in the amount of metal Ag. This result suggests that Ag⁺ ions participated in the photoreaction.

The effect of H₂ reduction of Ag-loaded TiO₂ on N₂O decomposition activity was investigated. One gram of photocatalyst was reduced under a H₂ gas stream (50 cm³ min⁻¹) at 373 or 573 K for 30 min and was transferred into the reaction vessel. N₂O decomposition activity was measured in the presence of methanol (0.63 kPa) and water vapor (1.4 kPa). As shown in Table 3, H₂ reduction at 373 K on

TABLE 3
Effect of H₂ Reduction of Ag-Loaded TiO₂ on Photocatalytic Activity

Sample	H ₂ reduction temperature	N ₂ O decomposition rate ^a (μmol h ⁻¹ g ⁻¹)
PD0.085	—	40.8
PD0.085	373 K	22.2
DP0.67	—	8.3
DP0.67	373 K	10.5
DP0.67	573 K	4.2
IM0.90	—	7.9
IM0.90	373 K	12.4

^a N₂O decomposition rate calculated from the amount of N₂O decomposed during the initial 1 h.

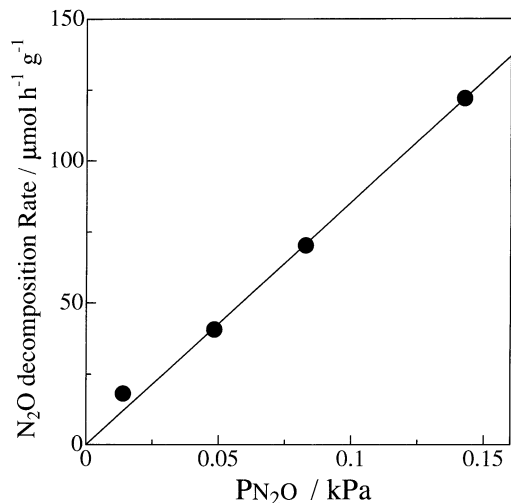


FIG. 9. Increase in N_2O decomposition rate with partial pressure of N_2O . Sample is Ag-photodeposited TiO_2 (PD0.16) (initial pressure of MeOH 0.63 kPa; H_2O 1.4 kPa).

DP0.67 or IM0.90 increased the activity by 20–50%. However, further reduction at 573 K on DP0.67 lowered the activity. These results suggest that a partially reduced Ag_2O phase possessed the high activity for N_2O decomposition and that the activity of metal Ag, which was formed by H_2 reduction at 573 K, was lower than the activity of Ag_2O . The activity of PD0.085 reduced at 373 K was lower than that of PD0.085 as prepared. This suggests that Ag was deposited in the form of partially reduced Ag_2O by the photodeposition method. H_2 reduction at 373 K on PD0.085 may form metal Ag with lower activity.

Figure 9 shows the relation between the partial pressure of N_2O (P_{N_2O}) and N_2O decomposition rate by PD0.16 photocatalyst. The decomposition rate was determined from the tangent of the curve that was fitted to the N_2O decay shown in Fig. 6a. The decomposition rate increased linearly with increasing N_2O partial pressure. Figure 10 shows the relation between the partial pressure of methanol (P_{MeOH}) and N_2O decomposition rate. In the absence of methanol in the reaction vessel, the photocatalytic decomposition of N_2O did not occur on Ag-photodeposited TiO_2 . The decomposition rate increased with P_{MeOH} ($0 < P_{MeOH} < 0.63$ kPa). These results suggest that the decomposition rate is determined by the amounts of N_2O and methanol adsorbed on the photocatalyst surface. The photocatalytic decomposition of N_2O was depressed if a higher pressure of methanol ($P_{MeOH} > 0.63$ kPa) was applied. It could be assumed that methanol is adsorbed on both the oxidation sites (TiO_2) and the reduction sites (Ag^+ sites), and this adsorption on the latter sites prevents N_2O from adsorbing, resulting in the depression of the N_2O decomposition.

The effect of water vapor on the photocatalytic decomposition of N_2O was investigated for PD0.085 (Fig. 11).

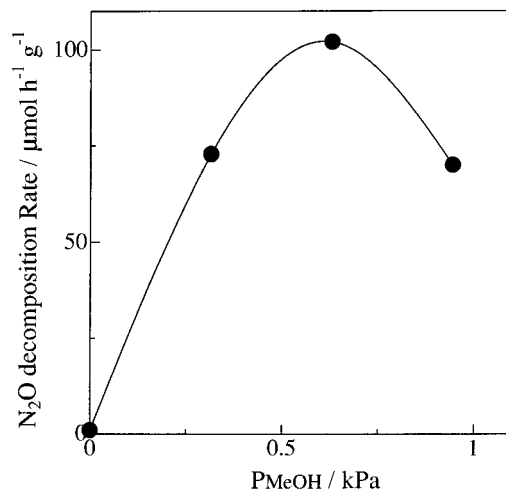


FIG. 10. Effect of partial pressure of methanol on N_2O decomposition rate with Ag-photodeposited TiO_2 (PD0.16). P_{N_2O} was 0.14 kPa, H_2O was not added.

The N_2O decomposition rate decreased with increasing water vapor pressure (P_{H_2O}). This result is opposite to the effect of P_{H_2O} on the photocatalytic decomposition of N_2O with Pt-loaded TiO_2 photocatalyst (7). In the decomposition with Pt- TiO_2 , N_2O was not decomposed in the absence of water, and it was inferred that N_2O was reduced by atomic hydrogen formed by the photoreduction of water on a platinum surface. In the N_2O decomposition by Ag-photodeposited TiO_2 , the above-mentioned mechanism was not effective. On the contrary, the adsorption of H_2O on Ag-photodeposited TiO_2 depressed the adsorption of N_2O and methanol and thus decreased the N_2O decomposition rate.

The photocatalytic decomposition of N_2O on Ag- TiO_2 is considered to be initiated by the formation of electrons

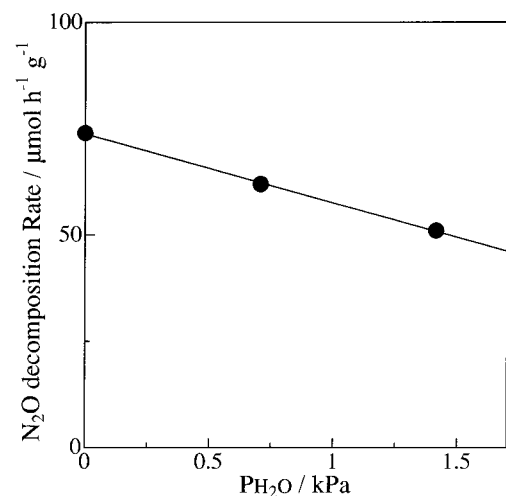
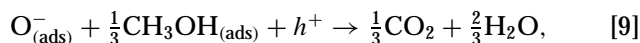
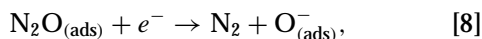
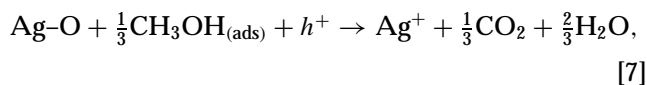
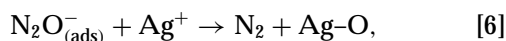
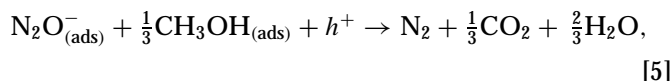
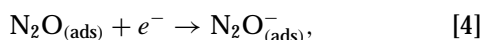
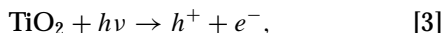


FIG. 11. Effect of partial pressure of H_2O on N_2O decomposition rate with Ag-photodeposited TiO_2 (PD0.085) (initial pressure of N_2O 0.14 kPa; MeOH 0.63 kPa).

(e^-) and holes (h^+) resulting from the photon absorption by TiO₂ (5–8, 11). The electrons transferred from TiO₂ via Ag⁺ reduce N₂O adsorbed on Ag⁺, and the holes oxidize methanol into CO₂ and H₂O (6). The reduction of N₂O to N₂ could be described in three ways: first, through the reaction of N₂O⁻ with methanol (Eqs. [4] and [5]); second, through the formation of Ag–O (Eqs. [4], [6], and [7]); and third, through the reaction of O⁻ with methanol (Eqs. [8] and [9]),



where N₂O_(ads), N₂O_(ads)⁻, CH₃OH_(ads), and O_(ads)⁻ are chemical species adsorbed on the photocatalyst surface. Ag–O denotes the Ag⁺ combined with an extra oxygen. In the photocatalytic decomposition of N₂O by titanium oxide anchored onto porous vycor glass (in the absence of Ag⁺ ions), the formation of N₂O⁻ has been confirmed by electron spin resonance (ESR) (5). Also, in the thermal catalytic decomposition on ZnO, the formation of N₂O⁻ has been reported (24). Since TiO₂ and ZnO do not have large nonstoichiometric composition, they could not retain extra oxide ions on their surface. On the other hand, Ag–TiO₂ includes Ag⁺ ions on its surface, which may be oxidized to form Ag²⁺ when accepting an oxide ion from N₂O. This suggests that the formation of Ag–O and O_(ads)⁻ on Ag–TiO₂ is possible. Therefore, the reaction pathway through Ag–O or O_(ads)⁻ is not rejected in the present study. The analyses of radical species or molecules adsorbed on the photocatalyst by ESR and Fourier transform infrared spectroscopy would clarify the pathway. We will describe the results of those analyses elsewhere.

CONCLUSION

The N₂O decomposition activity of Ag-photodeposited TiO₂ was much higher than that of Ag-TiO₂ prepared by deposition–precipitation or impregnation methods. The N₂O decomposition activity depends on the amount of pho-

todeposited Ag and the state of the Ag species. The highest activity was obtained for 0.16 wt% Ag-photodeposited TiO₂ (PD0.16). The TEM images and XPS spectra suggest that photodeposited Ag species were highly dispersed without aggregation, while aggregation occurred on the other photocatalysts. The photocatalytic decomposition rate of N₂O increased with increasing $P_{\text{N}_2\text{O}}$ or P_{MeOH} , whereas it decreased with increasing $P_{\text{H}_2\text{O}}$. The decomposition rate can be determined by the amounts of N₂O and methanol adsorbed on the photocatalyst surface. Highly dispersed Ag⁺ on PD0.16 probably enhanced the adsorption and decomposition of N₂O.

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